Refine Search

Search Results -

Terms	Documents
L2 and (nitrogen same polysilicon).clm.	10

Database:

US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search:

L5

Refine Search

Recall Text   Clear   Interrupt

Search History

DATE: Tuesday, July 10, 2007   Purge Queries   Printable Copy   Create Case

Set Name Query	Hit Count	Set Name
side by side		result set
DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
L5 L2 and (nitrogen same polysilicon).clm.	10	L5
L4 L2 and (nitrogen same polysilicon)	56	L4
L3 L2 and (nitrogen near7 polysilicon)	16	L3
L2 L1 and ((implant$ or doing or dopannt) near7 polysilicon)	538	L2
L1 (polysilicon near3 line) same pattern$	2233	L1

END OF SEARCH HISTORY